

RESPONSE TO NOTICE ON NON-COMPLIANT AMENDMENT UNDER 37 C.F.R § 1.121
U.S. Appln. No.: 09/851,113
Attorney Docket No.: Q64410

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

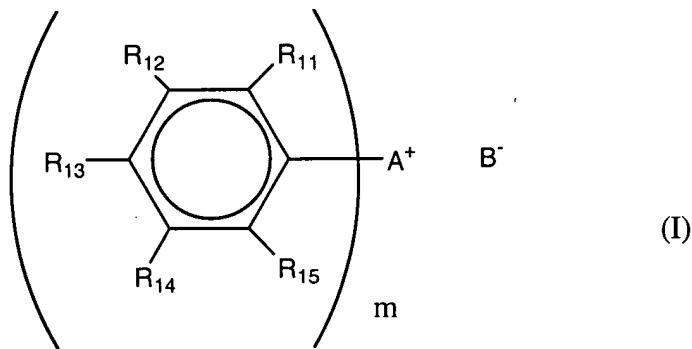
LISTING OF CLAIMS:

1. (Currently Amended): A positive radiation-sensitive composition comprising:
(a) a resin whose solubility in an alkali developer increases by the action of an acid;
(b) a compound that generates a carboxylic acid having a molecular weight of 100 or

less upon irradiation with an actinic ray or a radiant ray;

(c) a surfactant; and
(d) a solvent,

wherein compound (b) is present in an amount of from 1 to 20 wt% based upon the solid contents, and the compound (b) is a compound represented by the following formula (I):



wherein R₁₁, R₁₂, R₁₃, R₁₄ and R₁₅ each independently represents a hydrogen atom, a straight chain, branched or cyclic alkyl group, a straight chain, branched or cyclic alkoxy group, a hydroxyl group, a halogen atom, or -S-R₀; R₀ represents a straight chain, branched or cyclic alkyl

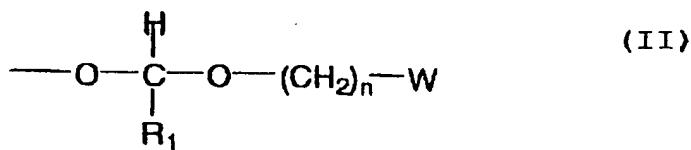
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hydroxyl group, a halogen atom, or $-S-R_0$; R_0 represents a straight chain, branched or cyclic alkyl group, or an aryl group, A^+ represents S^+ or Γ^+ ; B^- represents CH_3COO^- , $C_2H_5COO^-$ or $C_3H_7COO^-$; and m represents 2 or 3.

2. (original): The positive radiation-sensitive composition as claimed in claim 1, which further comprises (b') a compound that generates a sulfonic acid upon irradiation with an actinic ray or a radiant ray.

3. (canceled).

4. (original): The positive radiation-sensitive composition as claimed in claim 1, wherein the resin (a) has an acid-decomposable group represented by the following formula (II):



wherein R_1 represents an alkyl group having from 1 to 4 carbon atoms; W represents an amino group, an ammonium group, a mercapto group, a substituted or unsubstituted aryl group, a substituted or unsubstituted cycloalkyl group, or an organic group containing (i) at least one atom selected from the group consisting of an oxygen atom, a nitrogen atom, a sulfur atom, a phosphorus atom and a silicon atom, and (ii) at least one carbon atom; and n represents a natural number of from 1 to 4.

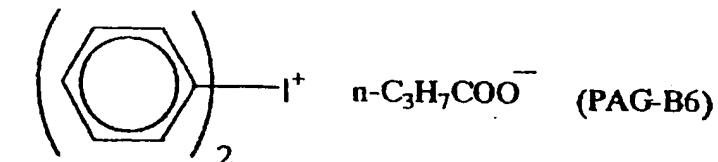
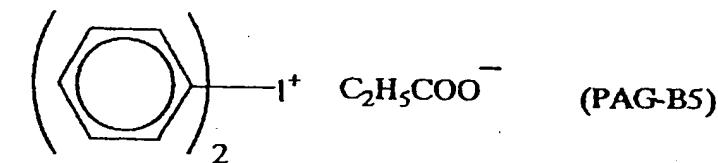
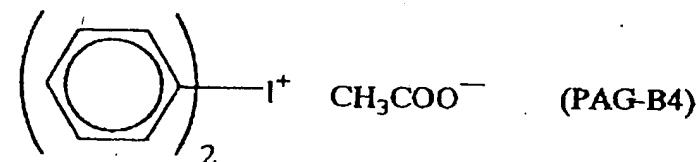
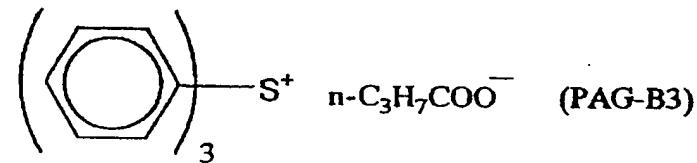
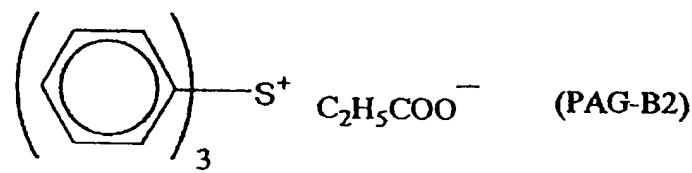
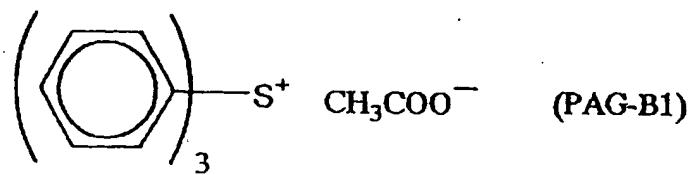
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5. (original): The positive radiation-sensitive composition as claimed in claim 1, wherein the resin (a) is a resin in which phenolic hydroxyl groups in an alkali-soluble resin are at least partly protected with the acid-decomposable group represented by the formula (II).

6. (original): The positive radiation-sensitive composition as claimed in claim 1, which further comprises an organic basic compound.

7. (original): The positive radiation-sensitive composition as claimed in claim 1, wherein the compound (b) is at least one compound selected from the group consisting of the following (PAG-B1) to (PAG-B6):

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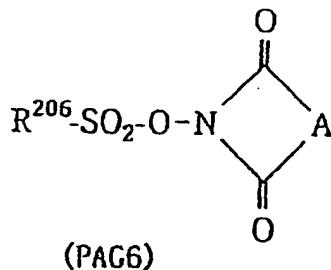
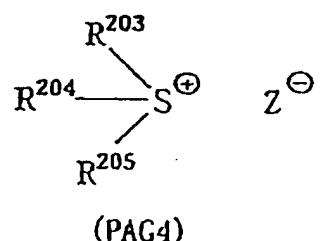
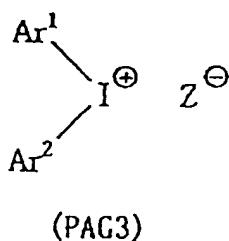


8. (currently amended): The positive radiation-sensitive composition as claimed in claim 7, wherein the compound (b) is at least one compound selected from the group consisting of the above (PAG-B1) and (PAG-B4).

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9. (canceled).

10. (original): The positive radiation-sensitive composition as claimed in claim 2, wherein the compound (b') is a compound represented by the following formula (PAG3), (PAG4) or (PAG6):

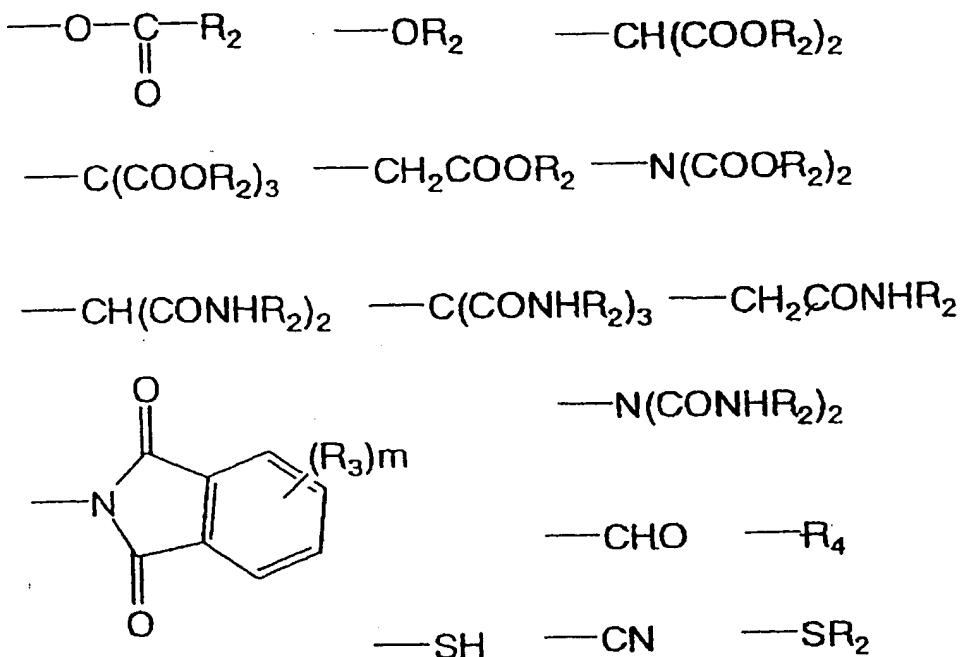


wherein Ar^1 and Ar^2 each independently represents a substituted or unsubstituted aryl group; R^{203} , R^{204} and R^{205} each independently represents a substituted or unsubstituted alkyl or aryl group; R^{206} represents a substituted or unsubstituted alkyl or aryl group; A represents a substituted or unsubstituted alkylene, alkenylene or arylene group.

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11. (original):The positive radiation-sensitive composition as claimed in claim 2, which contains the compound (b') in an amount of from 1 to 20 wt% based on the solid contents.

12. (original): The positive radiation-sensitive composition as claimed in claim 4, wherein W of said formula (II) is a group represented by the following formula:



wherein R_2 represents a hydrogen atom, a straight chain, branched or cyclic alkyl group having from 1 to 6 carbon atoms, a straight chain, branched or cyclic alkenyl group having from 2 to 6 carbon atoms, a substituted or unsubstituted aryl group, or a substituted or unsubstituted aralkyl group; R_3 represents a hydrogen atom, a straight chain, branched or cyclic alkyl group having from 1 to 6 carbon atoms, a straight chain, branched or cyclic alkoxy group having from 1 to 6 carbon atoms, a halogen atom, a nitro group, an amino group, a hydroxyl group, or a cyano group; R_4 represents a substituted or unsubstituted aryl group, or a substituted or unsubstituted

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cycloalkyl group having from 3 to 15 carbon atoms; m represents a natural number of from 1 to 4.

13. (original):The positive radiation-sensitive composition as claimed in claim 4, wherein the resin (a) is a resin in which 5 to 45 mol% of an entire phenolic hydroxyl groups in an alkali-soluble resin are protected with an acid-decomposable group represented by the formula (II).

14. (original):The positive radiation-sensitive composition as claimed in claim 1, wherein the resin (a) has a weight average molecular weight of from 3,000 to 80,000.

15. (original):The positive radiation-sensitive composition as claimed in claim 1, wherein the surfactant (c) contains at least one of a fluorine atom and a silicon atom.